

Lattice distortion of holmium doped bismuth ferrite nanofilms

YUN Qi (云 麒)¹, BAI Alima (白阿立玛)¹, ZHAO Shifeng (赵世峰)^{1,2,*}

(1. School of Physical Science and Technology, Inner Mongolia University, Hohhot 010021, China; 2. Inner Mongolia Key Lab of Nanoscience and Nanotechnology, Inner Mongolia University, Hohhot 010021, China)

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Abstract: Single-phase multiferroic BiFeO₃ and rare-earth metal of holmium (Ho) doped BiFeO₃ nanofilms were prepared on Pt (100)/Ti/SiO₂/Si wafer via solution-gelation technique. It was suggested that the lattice distortion happened with the lattice parameter of *d* decreasing after doping rare-earth metal of Ho. Meanwhile, the structure of nanofilms transformed from hexahedron phase to tetragonal phase after doping Ho. The analysis on X-ray photoelectron spectroscopy (XPS) indicated that the ratio of Fe³⁺ cations to Fe²⁺ cations increased with the increase of binding energy between Fe and O and decrease of that between Bi and O after doping Ho. The present work provided an available way on enhancing multiferroic of BiFeO₃ nanofilms.

Keywords: lattice distortion; holmium; bismuth ferrite; nanofilms; rare earths

There has been an increasing interest in multiferroics due to their fundamental properties, in which at least two ferroic orderings (ferromagnetism, ferroelectricity and ferroelasticity) appear simultaneously^[1,2]. However, most single-phase materials such as Cr₂O₃, YMnO₃, TbMnO₃ etc.^[2-4] exhibit multiferroic only at low temperature, which limits their further application in magnetoelectric devices. As one of the most outstanding single-phase lead-free multiferroics, BiFeO₃ has attracted continuous attention due to its high ferroelectric Curie ($T_{FE} \sim 1103$ K) and Neel ($T_N \sim 643$ K) temperature, which makes it one of the most important candidate from the views of the multifunctional applications perspective and engineering possibilities^[5,6].

BiFeO₃ based nanomaterials has been prepared with various methods and investigated greatly^[7-9] owing to its highly ferroelectric ordering temperature and magnetic ordering temperature. However some issues still need be solved before it is able to be practically applied in magnetoelectric devices such as leakage current and low ferromagnetism. Especially, for BiFeO₃ materials, the good ferroelectric is difficult to obtain due to the leakage current coming from Fe²⁺ within the BiFeO₃ films, which all restricts its multiferroic properties. Many attempts have been devoted to demonstrate that it is a very effective method to address such difficult problems by changing the structure from hexahedron phase to tetragonal phase^[10-15]. These efforts inspire an available way of decreasing leakage current and enhancing ferro-

electric properties for single-phase multiferroics.

So in this work, we prepared pure and Ho doped BiFeO₃ nanofilms by a simple solution-gelation method, and reported their crystalline structure. The analysis on X-ray diffraction and Raman scattering spectra analyses indicated that the crystal structure of nanofilms transformed from hexahedron phase to tetragonal phase and accompanied with lattice distortion that happened after doping rare-earth metal of Ho. The analysis on X-ray photoelectron spectroscopy (XPS) indicated that the ratio of Fe³⁺ cations to Fe²⁺ cations was on the rise, which could further decrease the leakage current. The origin of thus lattice distortion would be discussed in detail.

1 Experimental

1.1 Preparation of pure BiFeO₃ and Ho doped BiFeO₃ nanofilms

The pure BiFeO₃ and rare-earth metal of Ho doped BiFeO₃ nanofilms were prepared by solution-gelation process. The preparation method of the Ho doped BiFeO₃ precursor solution is as follows. Bi(NO₃)₃·5H₂O, Ho(NO₃)₃·5H₂O and Fe(NO₃)₃·9H₂O, which are of analytical grade, were dissolved in the glycol in proper proportions of 0.99:0.1:1, with excess 10% Bi for compensating the loss during annealing. Stir the solution until the solution is clear transparent, at this time, one by one add dilute nitric acid into the solution. Continue to stir until

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* **Corresponding author:** ZHAO Shifeng (E-mail: zhshf@imu.edu.cn; Tel.: +86-471-4993141)

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solution is clear transparent. The preparation method of pure BiFeO₃ solution is similar to the Ho doped BiFeO₃ solution. Bi(NO₃)₃·5H₂O and Fe(NO₃)₃·9H₂O were dissolved in the glycol in a proportion of 1.1:1, with excess 10% Bi to prepare BiFeO₃ solution.

Then the pure BiFeO₃ and Ho doped BiFeO₃ nanofilms were fabricated on Pt/Ti/SiO₂/Si (100) substrate with the precursor solution by spin coating the solution, and the films were dried at 280 °C on the thermostatic oven for 180 s. The dried deposited films were annealed at 600 °C for 5 min under the oxygen atmosphere with flow of 2 L/min. Repeat the above steps 12 times, and at the last time, the films were annealed at 600 °C for 30 min. The final thickness of nanofilms was about 300 nm.

1.2 Characterization of pure BiFeO₃ and Ho doped BiFeO₃ nanofilms

The surface morphology examinations for the pure and Ho doped BiFeO₃ nanofilms were carried out on a scanning electron microscope (SEM, Hitachi s-4800). The phase structures of samples were characterized by X-ray diffraction (XRD, Panalytical-Empyrean) on a D/MAX-RA diffractometer using Cu K α radiation. The Raman spectra were recorded on a confocal Raman spectroscope (NT-MDT NTEGRA Spectra) using a 473 nm excitation laser with an initial power of 10 mW. The binding energies of atoms and orbits for the samples were characterized by X-ray photoelectron spectroscopy (XPS, KRATOS-AMICUS). The cleaning treatments of nanofilms

were carried out using Ar ion bombardment. And all binding energies were calibrated with respect to C 1s spectral line at 284.8 eV. The leakage current of pure and Ho doped BiFeO₃ nanofilms capacitors were measured using a multiferroic tester system (MultiFerroc100V, Radient Technology, USA) at room temperature.

2 Results and discussion

2.1 XRD analysis

Fig. 1 shows the XRD patterns of the pure BiFeO₃ and Ho doped BiFeO₃ nanofilms. It is clear that both present nanofilms are polycrystalline and all of the observed diffraction peaks can be indexed to perovskite structure. Moreover, pure BiFeO₃ and Ho doped BiFeO₃ nanofilms are single phase while no other impurity phases such as Fe₂O₃, Bi₂O₃ or Bi₂Fe₄O₉ are detected.

Fig. 1(b), (c), and (d) further present the expanded view XRD patterns, which shows the changes in the location and angle of diffraction peak after doping Ho. Firstly, from the magnified XRD patterns in the vicinity of 2 θ around 23° and 32°, the separated (104) and (110) diffraction peaks are merged in the single peak after doping rare-earth metal of Ho, which suggests a phase transition appears after doping. To be specific, compared to pure BiFeO₃ nanofilms, the films were crystallized from the rhombohedral structure with space *R*-3c (161) to the orthorhombic structure after doping rare-

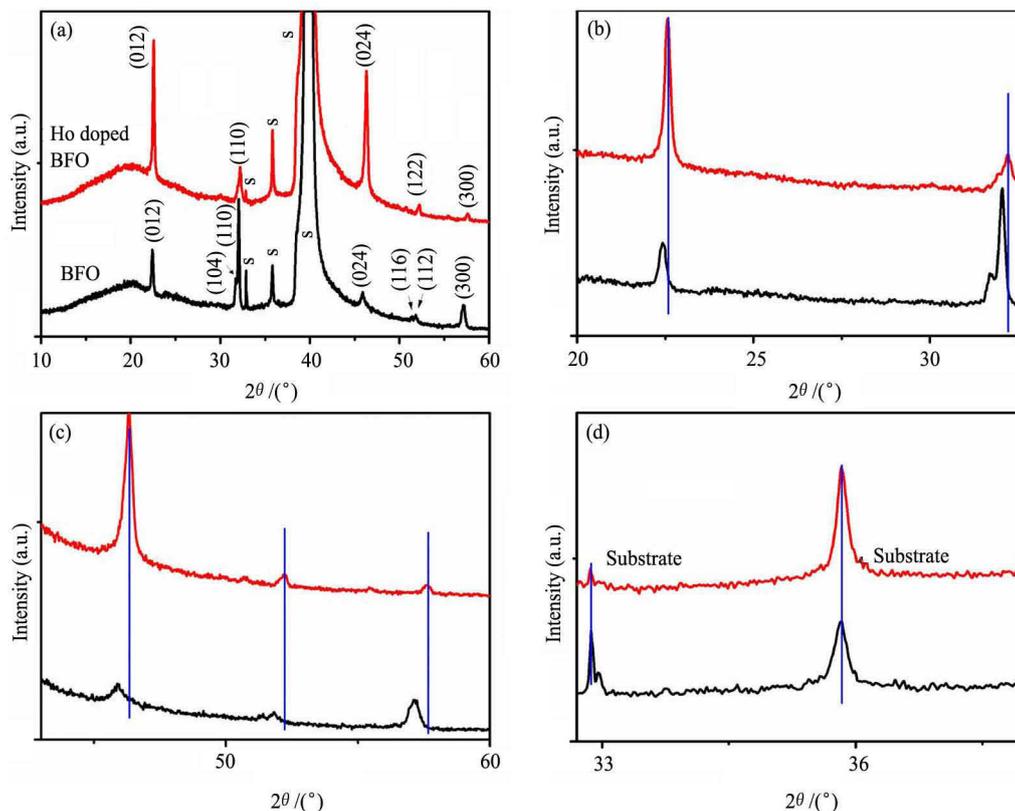


Fig. 1 XRD patterns of the typical pure BiFeO₃ and Ho doped BiFeO₃ nanofilm (a), expanded view XRD patterns around 20° to 33° (b), expanded view XRD patterns around 43° to 60° (c) and expanded view XRD patterns around characteristic peak of wafer (d)

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